

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	METHOD FOR AVOIDING OXIDE UNDERCUT DURING PRE-SILICIDE CLEAN FOR THIN SPACER FETs
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Application Number :

Confirmation Number:

First Named Applicant: Atul Ajmera

Attorney Docket Number: FIS920030112US1

Art Unit:

Examiner:

Search string: ( 6391732 or 6255165 or 6461951 or 6133106 or 5643824 or 20020076877 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6391732	2002-05-21	Gupta, et al.			
	2	6255165	2001-07-03	Thurgate, et al.			
	3	6461951	2002-10-08	Besser, et al.			
	4	6133106	2000-10-17	Evans, et al.			
	5	5643824	1997-07-01	Chien, et al.			

## US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
	1	20020076877	2002-06-20	Gupta, et al.			

## Signature

Examiner Name	Date